



# 41/H  
9/30/03 (N-E)  
Docket No.: M4065.0319/P319  
(PATENT)  
Adm H

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:  
Ronald A. Weimer, et al.

Application No.: 09/296,835

Group Art Unit: 2813

Filed: April 22, 1999

Examiner: Erik J. Kielin

For: FABRICATION OF DRAM AND OTHER  
SEMICONDUCTOR DEVICES WITH AN  
INSULATING FILM USING A WET RAPID  
THERMAL OXIDATION PROCESS

AMENDMENT

U.S. Patent and Trademark Office  
2011 South Clark Place  
Customer Window  
Crystal Plaza Two, Lobby, Room 1B03  
Arlington, VA 22202

Dear Sir:

Responsive to the Office Action dated June 18, 2003, please amend the above-captioned U.S. Patent application as follows:

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SEP 25 2003  
TECHNOLOGY CENTER 2300